

1. Material Substrate GaAs (N Type)
 Epitaxial Layer GaAlAs (P/N Type)

2. Electrode N(Cathode) Side Gold Alloy
 P(Anode) Side Gold Alloy

3. Electro-Optical Characteristics

| Parameter | Symbo | Min | Typ | Max | Unit | Condition |
|-----------------|-----------------|-----|-----|------|------|-----------|
| Forward Voltage | V_F | | 1.5 | 1.55 | V | IF=100mA |
| Reverse Voltage | V_R | 8 | | | V | IR=10uA |
| Power | P_O | 20 | 25 | | mW | IF=100mA |
| Wavelength | λ_P | | 940 | | nm | IF=20mA |
| | $\Delta\lambda$ | | 45 | | nm | IF=20mA |

※ Note : Power is measured by Sorter E/T system with bare chip.

4. Mechanical Data

| | | | |
|---------------------|-------|-----------|---------|
| (a) Emission Area | ----- | 12.8mil x | 12.8mil |
| (b) Bottom Area | ----- | 13.8mil x | 13.8mil |
| (c) Bonding Pad | ----- | 150um | |
| (d) Chip Thickness | ----- | 11mil | |
| (e) Junction Height | ----- | 6.7mil | |

